Fatigue life of a microcantilever beam in bending

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The fatigue behavior of a microcantilever beam loaded by various magnetic forces is investigated. The MEMS fabrication techniques, such as exposure, lithography, etching, etc., are applied to construct the micro structures on a silicon wafer. FEM and SEM are employed to study the relations between fractographies, stresses, and strains. The experimental results indicate that the deformation, stress and strain increase as the magnetic force increases, while the fatigue cycle time decreases with the load. The fatigue life lies in the range of 1–5×10^7 cycles at 12–15 MPa produced by the magnetic flux. Fracture occurs at the location of the maximum stress as predicted by an analytical approach. © 2004 American Vacuum Society. [DOI: 10.1116/1.1821502]

I. INTRODUCTION

Long-term reliability is essential for the successful application of MEMS. It is indispensable to study the mechanical properties associated with the lifetime of a MEMS device at the microscale level. The tensile and bending test, fracture test and fatigue analysis of microsamples and thin films were surveyed in the previous works. A tensile testing method of thin films was proposed by Toshiyuki et al., using electrostatic forces. The free end of a cantilever beam is attached with the probe by an electrostatic force. The relationship between the displacement and the load reveals the mechanical properties of the structure. The mean tensile strength of each sample decreases with increasing specimen length. The mean tensile strength of a p-doped film is slightly lower than the nondoped films. The electrostatic comb drive can also be used to generate the tensile force to the specimen. The result reveals that the aluminum film survived on a tensile stress of roughly 616 MPa, larger than the value obtained by Mearmini and Hoffman, about 180 MPa for freestanding films. Haque et al., reported that the yielding stress on the specimen at the beam support is about 880 MPa, 49 times larger than the bulk yielding stress of pure aluminum (55 MPa). Fracture strength varies with different etching chemicals used during fabrication processes. The fracture strength of the specimen etched by EDP is approximately twice that of the beam manufactured by KOH. Wilson et al. found the fracture strength, 3.3 GPa in average, is exceedingly larger than that of the back side, 1.0 GPa in average, because of the difference in the surface finish, where the front side of the beam was etched by reactive ion etching (RIE) and the back side of the beam was etched by potassium hydroxide (KOH) anisotropic etching.

There are several approaches to observe the fatigue in MEMS. The failure occurs at various stress amplitudes and the reduction of the stiffness and the changes of the resonant frequency also indicate the fatigue behavior. Mulhstein et al., used the electrostatic comb drive actuator to apply the load to a notched cantilever beam. The results showed that the fatigue life in swinging motion ranged from about 10 s to 48 days, or 10^9–10^11 cycles before failure over stress amplitudes ranging from approximately 4 to 10 GPa. Ando et al., performed tensile-mode fatigue testing of silicon films. The fracture point can be identified by observing the change in the load. Schweiger and Kraft studied the fatigue behavior of various Ag film thicknesses on a SiO_2 cantilever beam. The mean stress levels ranged from 126 to 600 MPa and the damage was always observed after 3×10^6 cycles. The fracture occurs after the specimen has been tested for approximately 9864 s (2.74 h). A clear fatigue limit was not obtained in this study. The resonant frequency can also be applied to determine the fatigue life of the specimen. The drift of the resonant frequency indicates growth of the microdefect in a device. Mulhstein et al., observed that the resonant frequency decays with time due to the progressive decrease in the stiffness of the beam. The structure stiffness can also be adopted to define the fatigue life of the specimen. The stiffness decreases when fracture occurs at the interior of the structure. Li et al., used the nanoindentor to apply an oscillation load on a double clamped Si beam. The sharp decrease in contact stiffness illustrate what fatigue damage has produced, approximately at 0.6×10^4 cycles.

In this research, investigations on material properties, including fatigue, are performed subject to low-frequency loading, which deviates from many applications of MEMS devices. This paper reveals the fatigue behavior of a polysilicon beam subject to a high-frequency magnetic actuation and measured by a noncontact instrument. The results help explore the fatigue property of MEMS components and develop the test method for reliability standard.

II. THEORETICAL ANALYSIS OF FATIGUE

A. Sample and loading

The microcantilever beam is fabricated by bulk micromachining. The structure consists of two layers, a single crystal silicon layer and a magnetic film. The beam length is...
800 μm, the width is 100 μm, and thickness equals 20 μm. The loads are produced by magnetic circuits. The microstructure with a magnetic film in the magnetic field produces the magnetic forces which induce beam bending along the direction of magnetic field, as illustrated in Fig. 1. The magnetic energy can be expressed as a volume integral

\[ U_m = \frac{1}{2} \int HBdv, \]  

(1)

where \( H \) is magnetic intensity, \( B \) is magnetic flux density, \( v \) stands for volume, and \( dv = S_m \cdot dy \). Hence

\[ dU_m = \frac{1}{2} \frac{B^2}{\mu_0} S_m dy, \]  

(2)

\( S_m \) is the area orthogonal to the magnetic field equal to the beam length \( (L) \) multiplied by the width \( (w) \), and \( \mu_0 \) is the magnetic permeability in free space. The magnetic force is the derivative with respect to the \( y \)-coordinate

\[ F_m = \frac{dU_m}{dy} = \frac{B^2}{2\mu_0} S_m. \]  

(3)

B. Approach of mechanics of materials

Assuming the magnet force \( (F_m) \) is uniformly distributed on the beam surface, one can employ classic mechanics of materials to obtain the beam deflection induced by a uniform load \( (P) \) as

\[ \nu = \frac{P x^2}{24 E I} \left( 6L^2 - 4Lx + x^2 \right), \]  

(4)

where \( L \) is the beam length, \( E \) is Young's modulus, and \( I \) is the moment inertia of the beam. The substitution of \( P = (F_m W) = (B^2 S_m / 2 \mu_0 W) \) yields the maximum deflection at \( x = L \),

\[ \nu_{\text{max}} = \frac{-B^2 L^3}{16 E I \mu_0}. \]  

(5)

The bending stress is derived by the classic mechanics of materials as

\[ \sigma = -\frac{My}{I}, \]  

(6)

where \( M \) is the bending moment

\[ M = EI \frac{d^2 \nu}{dx^2}. \]  

(7)

Substituting Eq. (4) into Eq. (7), one obtains

\[ M = -\frac{B^2}{48 \mu_0} \left( 12L^2 - 24Lx + 12x^2 \right). \]  

(8)

When \( x = 0 \), the substitution of Eq. (8) into Eq. (6) yields the corresponding maximum bending stress

\[ \sigma_{\text{max}} = \frac{B^2 L^3}{4 \mu_0 I}. \]  

(9)

C. Approach of finite element method

Finite element methods can be utilized to analyze the deformation, stress, and strain when a uniform load is applied on the structure. This paper presents the relations between deformation, stress, strain, and the location of the maximum stress by ANSYS simulations. The boundary conditions in ANSYS are fixed and the uniform loading is applied on the surface of the beam.

D. Prediction of fatigue life

The fatigue life of a material can be described by Eq. (10)

\[ \sigma_a = a N^b. \]  

(10)

This expression is widely adopted for the experimental data of fatigue test. The fatigue life \( (N) \) is a function of the alternating stress \( \sigma_a, \) \( a \) and \( b \) are experimentally determined constants. Equation (10) can be rewritten as

\[ N = \left( \frac{\sigma_a}{a} \right)^{1/b}. \]  

(11)

The value of \( \sigma_a \) is equal to half of the maximum bending stress \( \sigma_{\text{max}}. \) Substituting Eq. (9) into Eq. (11), one obtains
The bulk micromachining procedures, including lithography, exposure, etching, etc., are used to fabricate the structure of the microcantilever beam. A 1000 Å oxide film (SiO₂) is deposited on the silicon wafer followed by a 1500 Å nitride (Si₃N₄) film coated beyond the oxide as a passivation layer. The photoresist is then spin-coated on the wafer. Soft bake, in order to remove the solvent in the photoresist, is proceeded after coating. The following steps are to define the geometry of the beam by lithography, exposure and etching. The beam thickness is further patterned by the second mask. During the etching processes, KOH is used to determine the thickness. Afterwards, ICP is employed to etch through the thin film to release the microcantilever beam. The wafer is then cut to several pieces, each containing a microcantilever beam with a magnetic layer. The beam is finished as 800 × 100 × 20 μm³ in dimension.

The measuring facilities consist of a magnetic testing stage, a laser displacement meter, an oscilloscope, and a Gauss meter. The structure is fixed on the magnetic testing stage, where various magnetic fields apply the loads on the beam. The laser displacement meter is used to detect the beam deflection, as illustrated in Fig. 1. The deformation data can be used to calculate the beam stresses and to estimate the fatigue life. The fatigue test lasts about 7 days and the total cycle time of the fatigue life is around 1–5 × 10⁷. Observations are made every 2 h to check if the cantilever beams break until the fatigue failure.

C. S–N fatigue curve of microcantilever beam

Figure 4 illustrates the S–N fatigue curve obtained in this study. The fatigue life decreases as the magnetic flux density increases. When the magnetic flux density is 0.098 T, the fatigue life of the microcantilever beam is 6 days and 15 hours, or 3.43 × 10⁷ cycles in total, under the magnetic loading of ±12 MPa. When the magnetic flux density increases to 0.11 T, the life of the beam lasts 5 days and 19 h or 3.0 × 10⁷ cycles, under the loading of ±14 MPa. At B = 0.12 T, the life becomes 5 days and 3 h, or 2.66 × 10⁷ cycles, under the loading of ±15 MPa. Based on the experimental results, the S–N fatigue curve of the beam is drawn in Fig. 4.
V. CONCLUSIONS

Based on the results of analytical predictions, simulations and the experiment described above, the following conclusions are drawn. The deformation, stress, and strain increase as the magnetic flux density rises, while the fatigue life of the microcantilever beam shortens when the magnetic flux density increases. The beam life is expected to be $1 - 5 \times 10^7$ cycles at the stress level of 12 - 15 MPa produced by the magnetic flux. The experimental data shows a lower level of response to the magnetic flux than the theoretical analysis when the loading is high, which can be attributed to the deposited magnetic film on the specimen. Fracture occurs at the location of the maximum stress as predicted by ANSYS.

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